

UK Patent Application GB 2 270 699 A

(16) Date of Publication 28.03.1994

(43) Date of A Publication 28.03.1994

(11) Application No 5377312.8	(31) INTEL® C11D 7/20 // (C11D 7/20; 7/20; 7/20)
(22) Date of filing 18.03.1993	(52) UKCI [Edition M] CSD DAA D122 D134 D203 D207 U18 S121 S124 S1515
(51) Priority Data (22) 21.03.1992 (33) FR	(62) Documents cited WPI Abstract Accession No. 92-223105/22-8 JPS10071190(A)/Saiti Glass Co.,Ltd.
(71) Applicant(s) EZ Allochem S.A. (incorporated in France) 4 & 6, Courte Micheline 10, F-92010 Paris France	(58) Field of Search UK CI, [Edition L] CSD DAA INT CI, C11D 7/20; 7/20 ONLINE DATABASES: WPI CLAIMS
(72) Inventor(s) Paschal Michael	
(74) Agent and/or Address for Services J A Kamp & Co 14 South Square, Gray's Inn, LONDON, WC1R 8AL, United Kingdom	

(54) Composition comprising 1,1,1,2,2-pentafluorobutane, methylane chloride and methanol, for the cleaning and/or drying of solid surfaces

(57) A cleaning composition comprises, by weight, 30 to 65 % 1,1,1,2,2-pentafluorobutane (F285-mfc), 30 to 60 % methylane chloride and 1 to 10 % methanol, which compounds form a positive azeotrope (B.p. = 32.1°C at normal pressure). This composition, optimally stabilised, may be used for the cleaning and/or the drying of solid surfaces, in particular for removing flux from printed circuits and for degreasing mechanical components.

- 1 -
COMPOSITION BASED ON 1,1,1,2,2-PENTAFLUOROBUTANE.
**METHYLENE CHLORIDE AND METHANOL, FOR THE CLEANING
 AND/OR DRYING OF SOLID SURFACES**

The present invention relates to a fluorinated hydrocarbon-containing composition which can be used in the applications of drying, cleaning, degreasing and drycleaning solid surfaces, in particular in the removal of flux and the cold cleaning of printed circuits.

1,1,2-trichloro-1,2,2-trichloroethane (known in the 10 profession under the name F113) is widely used in industry for the cleaning and degreasing of solid surfaces. Besides its application in electronics to the cleaning or solder fluxes in order to remove the surface-attaching flux which adheres to printed circuits, there may be mentioned its 15 applications to the degreasing of heavy-metal components and to the cleaning of mechanical components of high quality and high precision, such as, for example, gyroscopes and military or aerospace equipment. In its various applications, F113 is most often combined with other organic solvents (for example 20 methanol), preferably in the form of azeotropic or pseudoazeotropic mixtures which do not demix and which, used at reflux, have substantially the same composition in the vapour phase as in the liquid phase.

However, F113 is one of the completely halogenated 25 chlorofluorocarbons which are currently suspected of attacking or damaging stratospheric ozone.

In order to contribute to solving this problem, the

GB 2 270 699 A

present invention proposes to replace the F113-based compositions by a new composition based on methylene chloride, methanol and 1,1,1,3-pentafluorobutane. The latter compound, known in the profession under the name F365-mfc, has no destructive effect with respect to ozone (ODP = 0).

According to the present invention there is provided a composition which comprises from 30 to 69 % by weight F365-mfc, from 30 to 60 % methylene chloride and from 10 1 to 10 % methanol. Within the ranges specified, there exists an azeotrope whose boiling temperature is 32.1°C at normal atmospheric pressure (1.013 bar) and the composition according to the invention has a pseudazeotropic behaviour, that is to say the composition of the vapour and liquid phases is substantially the same, which is particularly advantageous for the applications envisaged. Preferably, the F365-mfc content is chosen between 49 and 61 % by weight, that of methylene chloride between 37 and 46 % by weight and that of methanol between 2 and 5 % by weight.

The composition according to the invention additionally has the significant advantage of not exhibiting an ignition point under the standard determination conditions (ASTM Standard D-3828); the composition is thus nonflammable. The F365-mfc/methylene chloride/methanol azeotrope is a positive azeotrope since its boiling point (32.1°C) is less than those of the three constituents (F365-mfc: 40°C; methylene chloride: 40°C; methanol: 65°C).

As in the known F113-based compositions, the composition according to the invention can advantageously be stabilised against hydrolysis and/or free-radical attacks which are capable of taking place in the cleaning processes by adding thereto a conventional stabilising agent such as, for example, a nitroalkane, an epoxide or a mixture of such compounds, it being possible for the proportion of stabilising agent to range from 0.01 to 5 % with respect to the total F365-mfc + methylene chloride + methanol weight.

The composition according to the invention can be used in the same applications and according to the same techniques as the prior F113-based compositions.

The following Examples further illustrate the present invention without limiting it.

EXAMPLE 1: DISCUSSION OF THE AZEOTROPE

100 g of methylene chloride, 50 g of methanol and 100 g of F365-mfc are introduced into the distillation flask of a distillation column (30 plates). The mixture is then put on total reflux for one hour to bring the system to equilibrium. At the temperature plateau (32.1°C), a fraction (approximately 50 g) is withdrawn and analysed by gas phase chromatography.

Examination of the results, recorded in the table below, indicates the presence of a F365-mfc/methylene chloride/methanol azeotrope.

COMPOSITION (% BY WEIGHT)			
	F165-mfc	CH ₂ Cl ₂	Methanol
Initial mixture	40	40	20
Withdrawn fraction	57	39.5	3.5

EXAMPLE 2: VERIFICATION OF THE AZOTROPIC
COMPOSITION

200 g of a mixture containing, by weight, 57 % F165-mfc, 39.5 % methylene chloride and 3.5 % methanol are introduced into the distillation flask of an adiabatic distillation column (30 plates). The mixture is then brought 15 to reflux for one hour to bring the system to equilibrium, then a fraction of approximately 50 g is drawn off and analysed, as are the distillation bottoms, by gas phase chromatography. The results recorded in the following table show the presence of a positive azeotrope since its boiling point is less than those of the pure constituents: F165-mfc, methylene chloride and methanol.

COMPOSITION (% BY WEIGHT)			
	F165-mfc	CH ₂ Cl ₂	Methanol
Initial mixture	57	39.5	3.5
Fraction collected	57	39.5	3.5
Distillation bottoms	57	39.5	3.5

Boiling temperature corrected for 1.013 bar: 32.1°C

This azeotrope, used for the cleaning of solder flux or in the degreasing of mechanical components, gives results which are as good as those given by the compositions 15 based on F165 and methanol.

EXHIBIT 2: COMPOSITION STABILISED BY NITROMETHANE
150 g of a mixture containing, by weight, 57 % F165-mfc, 39.4 % methylene chloride, 3.5 % methanol and 0.1 % nitromethane as stabilising agent are introduced into an 20 ultrasound cleaning vessel. After the system has been put on reflux for one hour, an aliquot of the vapour phase is withdrawn. Its analysis by gas phase chromatography shows the presence of nitromethane, which indicates that the mixture is stabilised in the vapour phase.

COMPOSITION (% by weight)				
	F365-mfc	CH ₂ Cl ₂	Methanol	CH ₃ NO ₂
Initial mixture	57	39.4	3.5	0.1
Vapour phase	57	39.5	3.49	0.01

5

EXAMPLE 4: COMPOSITION STABILISED BY PROPYLENE

OXIDE

If Example 3 is repeated, replacing nitromethane by propylene oxide, the following results are obtained:

COMPOSITION (% by weight)				
	F365-mfc	CH ₂ Cl ₂	Methanol	CH ₃ O
Initial mixture	57	39.4	3.5	0.1
Vapour phase	57	39.5	3.48	0.02

16

EXAMPLE 5: CLEANING OF SOLDER FLUX

200 g of the F365-mfc/methylene chloride/methanol azeotropic composition are introduced into an Arremasse ultrasonic vessel, and then the mixture is brought 25 to boiling temperature. Standard circuits (IPC-B-25 model), coated with solder flux and annealed in an oven for 30 seconds at 220°C,

are immersed for 3 minutes in the liquid at boiling point under ultrasound, and then rinsed in the vapour phase for 3 minutes.

After drying in air, viewing in oblique light 5 shows the complete absence of solder flux residue.

1. A composition comprising, by weight, from 30 to 69 & 1,1,1,3-pentanfluorobutane, from 30 to 60 % methylene chloride and from 1 to 10 % methanol.
2. A composition according to claim 1, containing, by weight, from 49 to 61 & 1,1,1,3-pentanfluorobutane, from 37 to 46 % methylene chloride, and from 2 to 5 % methanol.
3. A composition according to Claim 2, in the form of an azeotrope boiling at 32.1°C at normal pressure.
4. A composition according to any one of Claims 1 to 3, which additionally comprises at least one stabilising agent.
5. A composition according to Claim 4, in which the stabilising agent is a nitroalkane, an epoxide or a mixture thereof.
6. A composition according to Claim 4 or 5, in which the proportion of stabilising agent is from 0.01 to 5 % with respect to the total weight of the 1,1,1,3,3-pentafluorobutane + methylene chloride + methanol mixture.
7. A composition according to claim 1 substantially as described in the Examples.
8. Use of a composition as claimed in any one of Claims 1 to 7 for cleaning and/or drying of a solid surface.
9. Use according to claim 8 for removal of flux from a printed circuit or degreasing of mechanical components.

10. A method of drying, cleaning, degreasing or drycleaning a solid surface which method comprises applying to the solid surface a composition as claimed in any one of claims 1 to 7.

11. A method according to claim 10 wherein flux is removed from a printed circuit or mechanical components are degreased.

Relevant Technical Fields	
(i) UK CI (Ed. L)	CSD (DAA)
(ii) Int CI (Ed. S)	C11D 7/60, 7/50

Databases (see below)
(i) UK Patent Office collections of GB, EP, WO and US patent specifications.

(ii) ONLINE DATABASES: WPI, CLAIMS

Categories of documents

- X: Document indicating lack of novelty or of inventive step.
Y: Document indicating lack of inventive step if combined with one or more other documents of the same category.
A: Document indicating technological background and/or state of the art.

P: Document published on or after the declared priority date but before the filing date of the present application.

E: Patent document published on or after, but with priority date earlier than, the filing date of the present application.

R: Member of the same patent family, or corresponding document.

Category	Identity of document and relevant passages	Relevant to claim(s)
P X	WPI Abstract Accession No. 93-253064/32 and JP 51007190 A (ASAHI GLASS CO LTD)	1-11

Databases/The UK Patent Office database comprises classified collections of GB, EP, WO and US patent specifications as outlined periodically in the Official Journal (Patents). The online databases considered for search are also listed periodically in the Official Journal (Patents).

**This Page is Inserted by IFW Indexing and Scanning
Operations and is not part of the Official Record**

BEST AVAILABLE IMAGES

Defective images within this document are accurate representations of the original documents submitted by the applicant.

Defects in the images include but are not limited to the items checked:

BLACK BORDERS

IMAGE CUT OFF AT TOP, BOTTOM OR SIDES

FADED TEXT OR DRAWING

BLURRED OR ILLEGIBLE TEXT OR DRAWING

SKEWED/SLANTED IMAGES

COLOR OR BLACK AND WHITE PHOTOGRAPHS

GRAY SCALE DOCUMENTS

LINES OR MARKS ON ORIGINAL DOCUMENT

REFERENCE(S) OR EXHIBIT(S) SUBMITTED ARE POOR QUALITY

OTHER: _____

IMAGES ARE BEST AVAILABLE COPY.

As rescanning these documents will not correct the image problems checked, please do not report these problems to the IFW Image Problem Mailbox.